

# ELECTRONIC INFORMATION DISCLOSURE STATEMENT

Electronic Version v18

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## Title of Invention

[METHODS AND SYSTEMS FOR RESISTIVITY ANISOTROPY  
FORMATION ANALYSIS]

Application Number :

Confirmation Number:

First Named Applicant: Cheng Liu

Attorney Docket Number: 20.2807

Art Unit:

Examiner:

Search string: ( 5656930 or 6218841 or 5886526 or 6092024 or 5966013 or 5461562 or 5550473  
or 3166709 or 20020149997 or 20030018434 ).pn

## US Patent Documents

**Note: Applicant is not required to submit a paper copy of cited US Patent Documents**

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
	1	5656930	1997-08-12	Hagiwara			
	2	6218841	2001-04-17	Wu			
	3	5886526	1999-03-23	Wu			
	4	6092024	2000-07-18	Wu			
	5	5966013	1999-10-12	Hagiwara			
	6	5461562	1995-10-24	Tabanou et al.			
	7	5550473	1996-08-27	Klein			
	8	3166709	1959-04-17	Doll			

## US Published Applications

**Note: Applicant is not required to submit a paper copy of cited US Published Applications**

init	Cite.No.	Pub. No.	Date	Applicant	Kind	Class	Subclass
	1	20020149997	2002-10-17	Zhang et al.	A1		
	2	20030018434	2003-01-23	Kriegshauser et al.	A1		

## Signature

Examiner Name

Date